

Heraeus



OFM
Opaque Fused Materials
The standard for
new applications

Heraeus Quarzglas



OFM 70 flange
OD x ID: 300 x 250 (mm)



OFM 70 flange
OD x ID x L: 500 x 460 x 500 (mm)



OFM 70 bell jar
D x W x H: 1000 x 20 x 2200 (mm)



OFM 370 crucible
D x W x H: 400 x 10 x 600 (mm)



OFM 370 crucible
D x W x H: 500 x 15 x 800 (mm)



OFM 970 plate
Length x width x thickness: 400 x 200 x 20 (mm)



OFM 970 plate
D x W: 200 x 20 (mm)



OFM 970 flange
OD x ID: 180 x 140 (mm)



OFM 970 flange
OD x ID x L: 340 x 300 x 100 (mm)



OFM 970 tube
OD x W x L: 240 x 6 x 300 (mm)



OFM 970 tube
OD x W x L: 270 x 6 x 500 (mm)



OFM 970 tube
OD x W x L: 180 x 20 x 6100 (mm) acids

*An innovative material for
high-quality applications*

OFM

Opaque Fused Materials

OFM is an opaque quartz glass produced using an arc melting process.

The production process produces primarily rotationally symmetrical products such as tubes and crucibles.

Plates, dishes, blocks and thin-walled tubes can be also manufactured using additional hot re-forming processes.

Light scattering on fine bubbles causes parts made of OFM to be opaque-white or translucent, depending on raw material used.

OFM – grades and applications



OFM 70 – Rotosil®



is used primarily in processes requiring high temperatures and / or in processes which require a high resistance to corrosion. Moreover, its specific electrical and thermal characteristics can be of use in a wide range of applications.



OFM 370

Applications:

- Precious metals recycling
- Lighting industry
- High-temperature processes
- Electrostatic filter production
- Chemical process engineering (containers, tubes, dishes, etc.)
- Calcination and annealing processes.

OFM has a number of characteristics that are not found in combination in any other material:

- extremely low thermal expansion
- high resistance to thermal shock
- high deformation point
- low thermal conductivity
- high resistance to corrosive media
- high resistance to corrosive melts (e.g., Au, Ag)
- low spectral transmission



is primarily used in processes in which high temperature and high thermal shock resistance are needed. The high purity of the raw material combined with additional in-house purification enable this material to meet all the stringent requirements of the semiconductor industry.



OFM 970



was specially developed for high-temperature processes requiring high thermal insulation and high purity. It is the preferred material for use at extremely high temperatures in low impurity environments.

Applications:

- Photo voltaic industry
- Semiconductor industry
- Fibre optics industry
- Special glass applications

Applications:

- Manufacture of optical glasses for microlithography
- Semiconductor industry
- Fibre optics industry

- In the non-machined state, all OFM grades are distinguished by a glazed, non-porous and smooth inside surface. The outside surface is not glazed. It is polished during machining.

- An advanced welding technology makes it possible to combine different grades, including combinations with transparent quartz glass.

Technical Specifications: Additional technical information is available from the product data sheets on our website at <http://www.heraeus-quarzglas.com/ofm>

OFM 70 – chemical properties

Key to the symbols in the table:

- Neither the element nor the component reacts with OFM 70
- A reaction takes place only above the specified temperature
- Only the melt of the components reacts with OFM 70
- Either the element or the component reacts with OFM 70.

Elements	
<input type="radio"/> Ag	
<input type="radio"/> Al	immediate reaction 700 - 800 °C
<input type="radio"/> Au	
<input type="radio"/> Br	
<input type="radio"/> C	only above 1.500 °C
<input type="radio"/> Ca	only above 600 °C
<input type="radio"/> Cd	
<input type="radio"/> Ce	only above 800 °C
<input type="radio"/> Cl	also no reaction with heat and moisture
<input checked="" type="radio"/> F	only in moist condition
<input type="radio"/> Hg	
<input type="radio"/> J	
<input checked="" type="radio"/> Li	only above 250 °C
<input type="radio"/> Mg	immediate reaction 700 - 800 °C
<input type="radio"/> Mn	
<input type="radio"/> Mo	
<input type="radio"/> Na	reacts only in vaporized state
<input checked="" type="radio"/> P	
<input type="radio"/> Pb	
<input type="radio"/> Pt	
<input type="radio"/> S	very sluggish reaction above 700 - 800 °C
<input checked="" type="radio"/> Si	
<input type="radio"/> Sn	
<input type="radio"/> Ti	
<input type="radio"/> W	
<input type="radio"/> Zn	

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